State of the Art in MEMS Deformable Mirrors



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Mirror Technology Days November 12, 2015

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Outline

- NASA SBIRS
 - Topography Improvements
 - Enhanced Reliability
 - TITLE OF PHASE I
- TDEM
- Commercialization of BMC DMs
- BMC mirrors in the field
- 10K+ actuator DM exploratory work



2040 Actuator (2K) Continuous Facesheet DM



MEMS DM Architecture





(smooth phase control)

(uncoupled control)



Deflected Actuator



Deformed Mirror Membrane



Deformed Segmented Mirror

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Topography Improvements



Topography Improvements in MEMS DMs for High-contrast, High-resolution Imaging Contract#: NNX13CP03C (closed 2015) SBIR Phase II

Objective: To develop a MEMS deformable mirror with reduce surface figure errors resulting from actuator "print-through" topography and stress-induced mirror scallop topography.



Delivered 3064 actuator device





Topography Improvements



Scalloping across mirror compared to heritage devices



Note 3064 aperture is 17mm while heritage is 10mm

Topography Improvements Things we learned



- Order of operation is critical when considering the thermal budget in microfabrication.
- Surface figure error in BMC DMs is dominated by reflow of the sacrificial material under the mirror layer.
- Phosphorus segregation, where polysilicon seeps out dopant materials, occurs non linearly with temperature.

Phosphorus Segregation



Optical Image and SEM of foreign material seen in the 3um electrode cuts of fabrication material leading to the reduced yield.

Topography Improvements Technological Achievements

• Delivered a 3064 element continuous facesheet DM with figure error better than a factor of 3 than what has been made thus far.



Unpowered Surface

With low order filtered

Enhanced Reliability



Enhanced Reliability MEMS Deformable Mirrors for Space Imaging Applications Contract #: NNX12CA50C (closed 2015) NASA Phase II SBIR

Objective: Demonstrate the ability to prevent single point failures resulting from electrical overstress caused by electronic or software faults that may occur during ground test or space-based operation

Delivered 2040 actuator device





Enhanced Reliability Actuator Design

Deflection versus voltage. Initial, after cycling 3 million times above critical voltage (295V).

Voltage (V)

Enhanced Reliability Things we learned



- The hardstops are good at preventing one-off failures due to a number of over voltage events.
- Damage can occur to electrodes if the voltage is higher than some threshold and applied for long enough.
- Modified Pachens curve predicts this electrical breakdown





Electrode Damage

Damage seen after 11 million flexure cycles to 295V

†. Wallash AJ, Levit L, editors. Electrical breakdown and ESD phenomena for devices with nanometer-to-micron gaps. Micromachining and Microfabrication; 2003: International Society for Optics and Photonics.

Enhanced Reliability

Technological Achievements

- Delivered 2040 element high reliability device with 96% yield.
- Reduced yield was a result of phosphorus segregation which has since been mitigated.
- Hard stops are shown to prevent actuator failures.
- We are further studying electrical breakdown

SEM of foreign material seen in the 3um electrode cuts of fabrication material leading to the reduced yield.

Voltage vs. Deflection Comparison of 2040-Actuator MEMS DMs with Enhanced Reliability Actuator Design and Heritage Actuator Design







Improved DMs



Improved Yield, Performance and Reliability of High-Actuator-Count Deformable Mirrors Contract#: NNX15CP39P (Ongoing) Phase I SBIR

Objective: Address known fabrication issues for high actuator count deformable mirrors

Keyhole Voids



Address these issues and integrate with the process for the best surface figure.

Phosphorus Segregation



Electric Breakdown



Damage seen on 3um spaced electrode held for 1 hour at 275V

Improved DMs



Keyhole Voids: the cause of the keyholes was determined and checks are done at this point in the process to ensure they will not occur.



Phosphorus Segregation: has been eliminated by implementing two process changes.

Electric Breakdown: Work is ongoing.



2um spaced electrode optical images 10 minutes apart with 275V applied

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TDEM Program



Ongoing Contract#: NNH12CQ27C TDEM/ROSES

MEMS Deformable Mirror Technology Development for Space-Based Exoplanet Detection

Objective: Demonstrate survivability of the BMC MEMS Deformable Mirror after exposure to dynamic mechanical environments close to those expected in space based coronagraph launch.

9 Mirrors ready for testing



5cm



Project Flow

- Issues with initial MEMS Fabrication
- Problems resolved, but delayed

Coronagraph Test Bed Component Insertion and Baseline Null Testing

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Coronagraph Test Bed Component Insertion and Baseline Null Testing

BMC Characterization



DMs Fabricated and Characterized Delivered to JPL and Princeton



Voltage v. Deflection CONTRACTION DEFLECTION CURVES SHAPING LIGHT DEFLECTION CURVES Serial Number: 25CW012#015-DM#1 1.40



Single Actuator Surface Figure



Active Flattening of DM Surface

Continuous DM Surface Data Powered Flat Image Circular Aperture (Tilt Removed)



Sinusoid Shape

4 Period, 400nm Amplitude



Test Bed Measurements/Characterization





JPL/VSG

- Influence function
- Repeatability
- Position stability
- Surface Shape



High Contrast Imaging Laboratory (HCIL) at Princeton University

- Test the performance of two DMs in series with a shaped pupil coronagraph
- Vary the size of the dark hole and its separation from the optical axis from 7 to 10 and -2 to 2 λ/D on each side of the image plane.

Schedule



r rojoor olari	September 2012	
Deliver "Engineering" DM to JPL	March 2014	
Deliver Test DMs to JPL	March 2015	
Deliver "Engineering" DMs to Princeton	April 2015	
Deliver Test DMs to Princeton	July 2015	
Characterization at JPL/Princeton	Ongoing	
Environmental testing at GSFC	1 month after return (with 1 month notice)	
Retesting at BMC	2 Weeks	
Retesting at JPL/Princeton		
Submit Whitepaper	1 month after receipt	
Submit Whitepaper 2012 2013 2014	1 month after receipt 2015 2016	
Submit Whitepaper 2012 2013 2014 Q4 Q1 Q2 Q3 Q4 Q1 Q2 Q3 BMC Fabrication Delay JPL	2015 2016 Q4 Q1 Q2 Q3 Q4 Q1 Q2 Q3	Q4
Submit Whitepaper 2012 2013 2014 Q4 Q1 Q2 Q3 Q4 Q1 Q2 Q3 BMC Fabrication Delay JPL Princeton Goddard	2015 2016 Q4 Q1 Q2 Q3 Q4 Q1 Q2 Q3	Q4
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New DMs for Commercialization Tip-Tilt-Piston (TTP) MEMS DM





Surface Figure



Individual segments with underlying actuators Individual segment 7 nm RMS over 760um

Used for Biomedical Imaging (2-photon)

Tip-Tilt-Piston MEMS DM





Stiff actuators results in low influence function, allowing for steeper tilt.

Pure piston (all 3 actuators) provides >4 um of stroke



TTP Electromechanical Performance



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On-Sky Instruments using BMC Mirrors



ROBO-AO/Palomar Observatory

- Multi-DM Installed 2011
- Low-cost, autonomous, integrated laser adaptive optics system
- Over 19,000 targets from exoplanet follow-up to young-star binarity surveys



Shane-AO, Lick Observatory

- Kilo-DM installed 2013
- Visible Light Laser Guidestar Experiments



Shane AO offShane AO onPortion of the M92 globular cluster taken in H band.



On-Sky Instruments using BMC Mirrors

The Subaru Coronographic Imager with Extreme Adaptive Optics (SCExAO)

- <u>2k-DM</u> Installed at the Subaru Telescope in 2012
- First light achieved 2013
- Results showed improvement in Strehl from 23.9% 94.4%
- On sky testing going on now



The Gemini Planet Imager

- <u>4092 actuator DM</u> with 3.5µm stroke,
- Deployed on the 8-meter Gemini South Telescope
- First light in 2013
- 2015 Discovered a 'Young Jupiter' 51 Eridani b shows strongest methane signature ever detected on an alien planet.





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10k + exploratory development work



Boston University NSF Award# AST-1105615 BMC Subaward# 450000912

Limited by electrical interconnects

- Wirebond for each actuator
- Span of active optical surface scales with N
- Span of the chip scales with N²
- Limits number of die on a wafer
- Increases the likely hood of a single point defect causing short/failure
- Plan for development of high density Through Wafer Via (TWV) interconnects

Through-Wafer-Via DM Fabrication Prototype















- A new process was developed
- Eliminates wire bonds
- Instead Uses through-wafer-via (TWV) technology
- Challenge is now in packaging of TWV devices
- 140 actuator, 500 actuator, and 2000 actuator devices were fabricated and tested



Flex cable packaging of 2000 actuator TWV devices



Polymer bump bonds

Chip and cable curvature over large area device diminished bond yield (~70%)

Testing of well-bonded sections yielded reliable actuation performance



Conclusion



- Results from our Phase II reliability and topography programs show good promise for next generation MEMS DMs.
- Testing is ongoing with our TDEM program. Parts are ready to test at JPL, and Princeton.
- A phase I effort to address fabrication issues is making progress.
- New TTP mirrors are now commercially available.
- Some exploratory work on 10K+ actuator devices has been performed.

Acknowledgements

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 - Contract#: NNH12CQ27C TDEM/ROSES
 - Contract #: NNX12CA50C NASA Phase II SBIR
 - Contract#: NNX13CP03C NASA Phase II SBIR
 - Contract#: NNX15CP39P NASA Phase I SBIR





Thank You

Questions?



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